

L Number	Hits	Search T xt	DB	Time stamp
-	3	(gate adj line).clm. and (gate n ar (in ulating or di le tric)).clm. and (storage n ar2 electr de).clm. and ((pr tective r protectant or protect or protecting) near layer).clm. and (contact or via or hole).clm. and (capacitor near electrode).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:22
-	12	(gate adj line).clm. and (gate near (insulating or dielectric)).clm. and (storage near2 electrode).clm. and (contact or via or hole).clm. and (capacitor near electrode).clm. and (method or process).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:23
-	12	(gate adj line).clm. and (gate near (insulating or dielectric)).clm. and (storage near2 electrode).clm. and (contact or via or hole).clm. and (capacitor near electrode).clm. and (method or process).clm. and (storage near capacitor).ti,ab,clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:27
-	8	(gate adj line).clm. and (gate near (insulating or dielectric)).clm. and (storage near2 electrode).clm. and (contact or via or hole).clm. and (capacitor near electrode).clm. and (method or process).clm. and (storage near capacitor).ti,ab,clm. and (passivation).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:27
-	8	(gate adj line).clm. and (gate near (insulating or dielectric)).clm. and (storage near2 electrode).clm. and (contact or via or hole).clm. and (capacitor near electrode).clm. and (method or process).clm. and (storage near capacitor).ti,ab,clm. and (passivation).clm. and pixel.clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:27
-	12	(gate adj line).clm. and (gate near (insulating or dielectric)).clm. and (storage near2 electrode).clm. and (contact or via or hole).clm. and (capacitor near electrode).clm. and (method or process).clm. and (storage near capacitor).ti,ab,clm. and pixel.clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:27
-	10	(gate adj line).clm. and (gate near (insulating or dielectric)).clm. and (storage near2 electrode).clm. and (contact or via or hole).clm. and (capacitor near electrode).clm. and (method or process).clm. and (storage near capacit r).ti,ab,clm. and pix l.clm. and (gate adj insulating adj layer). lm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:28

-	8	(gate adj lin).clm. and (gat n ar (insulating r diele tric)).clm. and (storage near2 electr de).clm. and (conta t or via r hol).clm. and (capacitor near ele trode).clm. and (method or process).clm. and (storage near capacitor).ti,ab,clm. and pixel.clm. and (gate adj insulating adj layer).clm. and (contact adj hole).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/12 15:29
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